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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Date: January 26, 2005

CHUNG J. LEE and ATUL KUMAR

Serial No. : 10/816,205

Group Art Unit 2811

Filed : March 31, 2004

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UNDER 37 C.F.R. §§ 1.56, 1.97, and 1.98

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**TRANSMITTAL
FORM**

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Total Number of Pages in This Submission

9+

Application Number

10/816,205

Filing Date

March 31, 2004

First Named Inventor

Chung J. Lee

Art Unit

2811

Examiner Name

Attorney Docket Number

DSI 301

ENCLOSURES (Check all that apply)

<input type="checkbox"/> Fee Transmittal Form	<input type="checkbox"/> Drawing(s)	<input type="checkbox"/> After Allowance Communication to TC
<input type="checkbox"/> Fee Attached	<input type="checkbox"/> Licensing-related Papers	<input type="checkbox"/> Appeal Communication to Board of Appeals and Interferences
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<input type="checkbox"/> Express Abandonment Request	<input type="checkbox"/> Request for Refund	1. PTO-1449 Forms (6)
<input checked="" type="checkbox"/> Information Disclosure Statement (Supplemental)	<input type="checkbox"/> CD, Number of CD(s) _____	2. Foreign References (12)
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SIGNATURE OF APPLICANT, ATTORNEY, OR AGENT

Firm Name	Alleman Hall McCoy Russell & Tuttle LLP		
Signature	<i>M. Matthews Hall</i>		
Printed name	M. Matthews Hall		
Date	January 26, 2005	Reg. No.	43,653

CERTIFICATE OF TRANSMISSION/MAILING

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Typed or printed name	Renee Knight	Date	January 26, 2005

This collection of information is required by 37 CFR 1.5. The information is required to obtain or retain a benefit by the public which is to file (and by the USPTO to process) an application. Confidentiality is governed by 35 U.S.C. 122 and 37 CFR 1.11 and 1.14. This collection is estimated to 2 hours to complete, including gathering, preparing, and submitting the completed application form to the USPTO. Time will vary depending upon the individual case. Any comments on the amount of time you require to complete this form and/or suggestions for reducing this burden, should be sent to the Chief Information Officer, U.S. Patent and Trademark Office, U.S. Department of Commerce, P.O. Box 1450, Alexandria, VA 22313-1450. DO NOT SEND FEES OR COMPLETED FORMS TO THIS ADDRESS. SEND TO: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

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CONTENT OF DISCLOSURE

This Supplemental Information Disclosure Statement includes (1) six pages of PTO-1449 forms, and (2) a legible copy of each foreign and non-patent reference, if any, listed on the form(s). However, because this application was filed on or after July 1, 2003, no copies of U.S. patents or published U.S. patent applications are included.

TIMING OF DISCLOSURE / FEE INFORMATION

This Supplemental Information Disclosure Statement is being filed, to the best of the undersigned's knowledge, either (1) before the mailing of a first Office action on the merits, or (2) before the mailing of a first Office action after the filing of a request for continued examination under 37 C.F.R. § 1.114. Therefore, in accordance with 37 C.F.R. § 1.97(b), no fee or statement under 37 C.F.R. § 1.97(e) is required.

Please contact the undersigned with any questions or comments regarding this Supplemental Information Disclosure Statement.

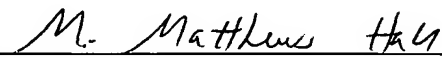
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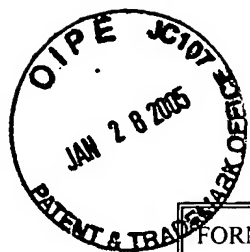
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Renee Knight

Respectfully submitted,

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SHEET 1 OF 6

FORM PTO-1449 INFORMATION DISCLOSURE CITATION IN AN APPLICATION		DOCKET NUMBER DSI 301		APPLICATION NUMBER 10/816,205		
		APPLICANTS Chung J. Lee and Atul Kumar				
		FILING DATE March 31, 2004		GROUP ART UNIT 2811		
U.S. PATENT DOCUMENTS						
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FIL. DATE IF APPROP.
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OTHER DOCUMENTS						
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	2003-0198578	10/23/2003	Lee			
	2003-0196680	10/23/2003	Lee			
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